

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Appl. No. : 10/537,363 Confirmation No. 3423
Applicant : Wieve DE BOER
Filed : June 2, 2005
TC/A.U. : 1763
Examiner : NG, James Wai Heung

Docket No. : **US02 0527 US**
Customer No. : 65913

Title: **SYSTEM AND METHOD FOR SUPPRESSION OF WAFER
TEMPERATURE DRIFT IN COLD-WELL CVD SYSTEMS**

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

RESPONSE & AMENDMENT

Sir:

In response to the Office Action of July 29, 2008, in which a restriction requirement was made, Applicant elects to prosecute the claims of Group I, with traverse.

Amendments to the Specification there are no amendments in this paper.

Amendments to the Claims there are no amendments in this paper.

Remarks/Arguments begin on page 2 of this paper.